



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#9/EXT
(1)
7/22/02
V/d

In re application of:

Liming Tsau

Appl. No. 09/753,664

Filed: January 4, 2001

For: **High Density Metal Capacitor
Using Via Etch Stopping Layer as
Field Dielectric in Dual-
Damascene Interconnect Process**

Confirmation No. 1902

Art Unit: 2823

Examiner: Brairton, Scott A.

Atty. Docket: 1875.0230000

TECHNICAL
1875.0230000

Petition For Extension of Time Under 37 C.F.R. § 1.136(a)(1)

Commissioner for Patents
Washington, D.C. 20231

Sir:

It is hereby requested that the period for replying to the outstanding Office Action be extended one (1) month from June 27, 2002 to July 27, 2002 by the filing of this Petition and fee payment.

The petition fee (37 C.F.R. § 1.17(a)) is believed to be \$110.00 for a one (1) month extension for a large entity. Fee payment is provided in our accompanying Check No. 35729 However, if extensions of time under 37 C.F.R. § 1.136 other than those provided herewith are required to prevent abandonment of the present patent application, then such extensions of time are hereby petitioned.

The U.S. Patent and Trademark Office is hereby authorized to charge any fee deficiency, or credit any overpayment, to our Deposit Account No. 19-0036.

Respectfully submitted,

STERNE, KESSLER, GOLDSTEIN & FOX P.L.L.C.

Donald J. Featherstone
Attorney for Applicant
Registration No. 33,876

Date: 7/3/02.

1100 New York Avenue, N.W., Suite 600
Washington, D.C. 20005-3934
(202) 371-2600

DJF/LGK/agj
ODMA\HODMA\SKGF_DC1.29636.1